

# AFM report to Coastline Optic

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### **AFM report to Coastline Optic**

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AFM Specialist: Tommaso Pardini

**Date:** June 19, 2015

**Purpose:** This report briefly outlines results from AFM on Coastline plano-plano fused silica substrate serial number 1.0-FS-PL-3356 to establish if high spatial frequency roughness meets requirements.

**Note:** Further dissemination of results provided in this report must include:

"This work was performed under the auspices of the U.S. Department of Energy by Lawrence Livermore National Laboratory under Contract DE-AC52-07NA27344. Funding was provided by NASA's Astrophysics Research and Analysis (APRA) program. LLNL-TR-673900."

#### **Results**

Sketch below approximately indicates where images on subsequent pages were obtained. Radial PSD plots were evaluated and noted to have acceptable performance at high frequency. Some concern that dimples and troughs (most noticeably in .001, .004 and .005) could have adverse effect on performance. Best effort to limit these required.

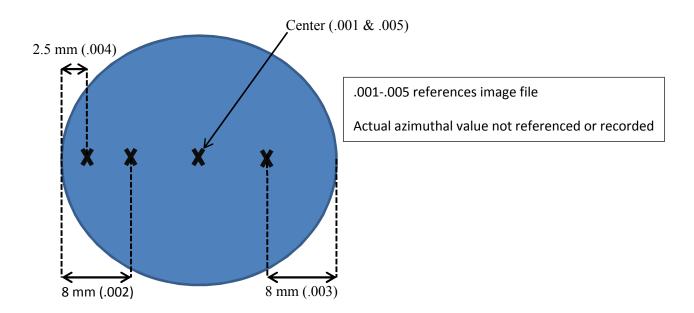
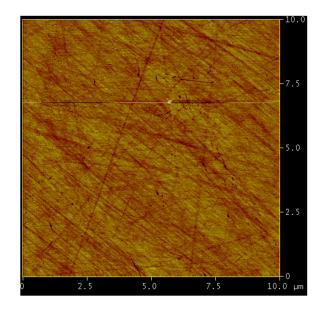
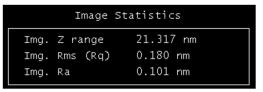
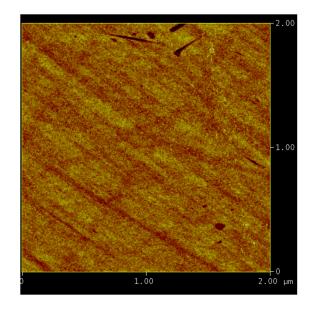


Figure 1: Sketch of approximate location of measurement areas.





# 10um.001



## Image Statistics Img. Z range 2.516 nm Img. Rms (Rq) 0.142 nm Img. Ra 0.107 nm

2um.001

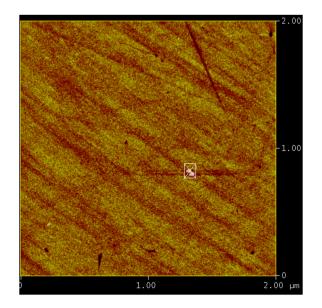
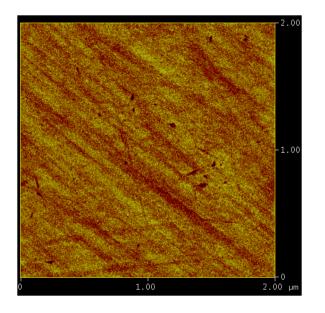
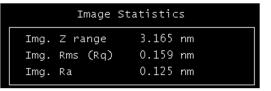


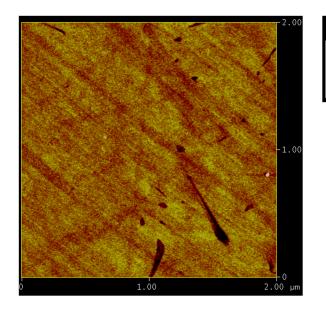
Image Statistics			
Img.	Z range	3.221	nm
Img.	Rms (Rq)	0.153	nm
Img.	Ra	0.119	nm

2um.002



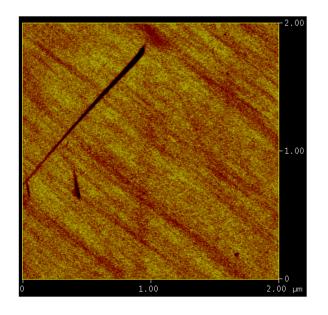


2um.003



Imag	Statistics
Img. Z range Img. Rms (Rq Img. Ra	

2um.004





2um.005